## Innovation of Dual Fractional Rejuvenation & Shining the Skir

#### Total Fractional Capabilities

As the newest assimption of the fractional technology of ACTION II allows to selected process balano depth and comparison control with a pairless process The specialized multiple stacking technology of ACTION II supplies adjustable ablantic depth and thermal couplication content. The dynamic moving technologies available to doneren the operation time. The fractional generacity is available to doneren the operation time. The fractional generacity and the fractional fractional and up follow moving action technology leads to a sight healing process and minimal downtime.

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	Specific	ations	
	Laser Type		
	Operating	Mode	
	Beam Prof	fe	
	Pulse Ener	gy	
	Pulse Wid	th	
		Zoom H/P	Normal
	Spot Size		Long Pulse
245		Shining Peel H/I	
		Fractional H/P	
	Handpiece	Auto Sensing	
	Pulse Rate		
	User Inter	ace	
	Memory		
	Aiming Be	am	
	Dimension		
	Weight		



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# Easy & Optimal Multiplexing Platform



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Fractional Rejuvenation with Dual Operation Modes

No More Limitations to Conventional Resurfacing and Coagulation

ACTION II indications include wrinkles, acne scars, large pores, skin tone, texture improvement and the removal of benign epidermal lesions, with additional possibilities as new treatment techniques are explored.

The latest ACTION II features the conventional micro-pulse mode for micro laser resurfacing and the long pulse mode for coagulation. The maximum 1000 ms pulse width in the long pulse mode is expanding new applications. Specialized fractional technology and the Shining Peel technique supply more gentle fractional rejuvenation and deliver a real glow to the skin.

ACTION III is equipped with lutronic's proprietary Controlled Depth Ablation (CDAI technology and Top-Hat beam profile allowing precision control of ablation depth layer-by-layer with minimal collateral heat diffusion. This function maintains a consistent fluence for uniform results. This versatile laser system is good for both conventional micro laser resultariation and deep resultations with the long public cogulution procedure. Properly controlled residual heating minimizes added disconfort, making procedures with ACTION II virtually painess.

For the fractional approach, Shining Peel and various indications, ACTION II is the ideal choice, reliably delivering controllable thermal energy with less patient discomfort, reduced treatment times and less patient downtime so that you may achieve higher patient satisfaction bevels and improved revenue results. Shining Peel, the most gentle peeling technique for Fine Wrinkles Large Pores and Skin Rejuvenation without downtime

### Shining Peel for Gentle Rejuvenation

ining yees a data to be use pateng application in writes and pate pater and similarity and in uncluding and interness, downline of an orient is grine pecing including simulates callagen emodeling by deversing percent samonts of laser ency; to the skin without immediate ablacion of the epidemiss ining here decreases the chance of PH since the catalot layer of the skin is legit intact during treatment.



ACTION II is equipped with essential and convenient advantages such as the triple operation mode and the auto-detected triple handpieces for versatile clinical applications.

## Auto-Detected Triple Handpieces & Spot Size

Triple Operation Mode
Normal mode
Fractional mode
Max 100 ms Long Pulse mode - Fracti

Adjustable Aiming Beam

is available eam red diode i according



